## Status of laser annealing of Nb coated samples

**Arturs Medvids** 



## Influence of Laser Radiation on Surface Roughness of Nb/Cu Structure



## **Experimental**

Nb films were deposited by HiPIMS (magnetron sputtering) with pulse width of  $100 \,\mu s$ , repetition rate of  $200 \,Hz$ , average plasma current of  $600 \,mA$ , peak current of  $40 \,A$  and a krypton pressure of  $500 \,mTorr$ . Sample Nr.  $1/7/16 - 500 \,°C$  deposition temperature with 0V DC substrate bias (grounded) for 240 mins onto copper substrate which was preannealed to  $700 \,°C$  for 12 hours prior to deposition.

The sample was irradiated by Nd:YAG laser ( $\lambda$ = 1.064  $\mu$ m,  $\tau$  =6 ns and intensity I=193.7 MW/cm<sup>2</sup>) in scanning mode with step 5 $\mu$ m in Ar atmosphere.

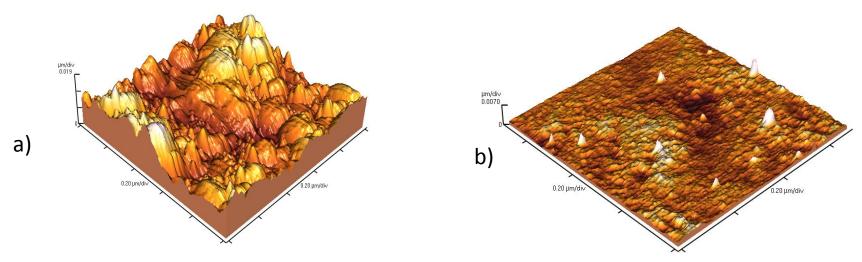


Fig.1. 3D AFM images of Nb/Cu sample (1/7/16) : non-irradiated (a) and irradiated by Nd:YAG at intensity  $I=200.0~MW/cm^2$  (b).

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b) irradiated

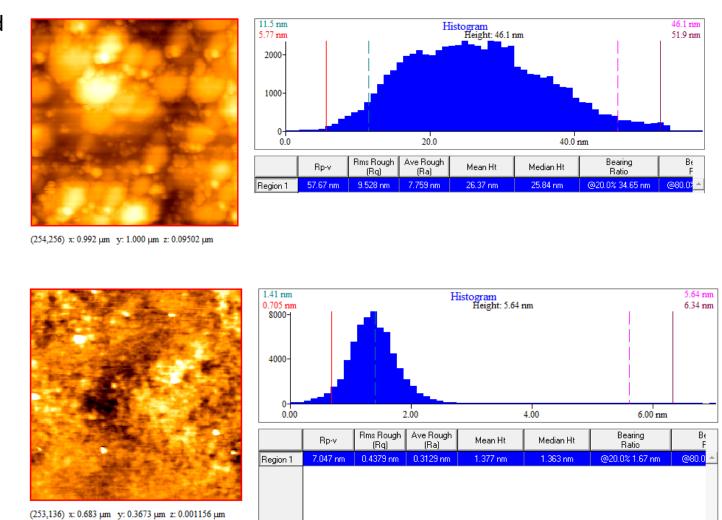


Fig.2. 2D AFM images of the non-irradiated (a) and the irradiated (b) Nb/Cu sample (1/7/16) and region analyses. The Nb surface roughness RMS (Root Mean Square Roughness) of the **non-irradiated is 9.528nm** and for laser **irradiated it is 1.233 nm**.

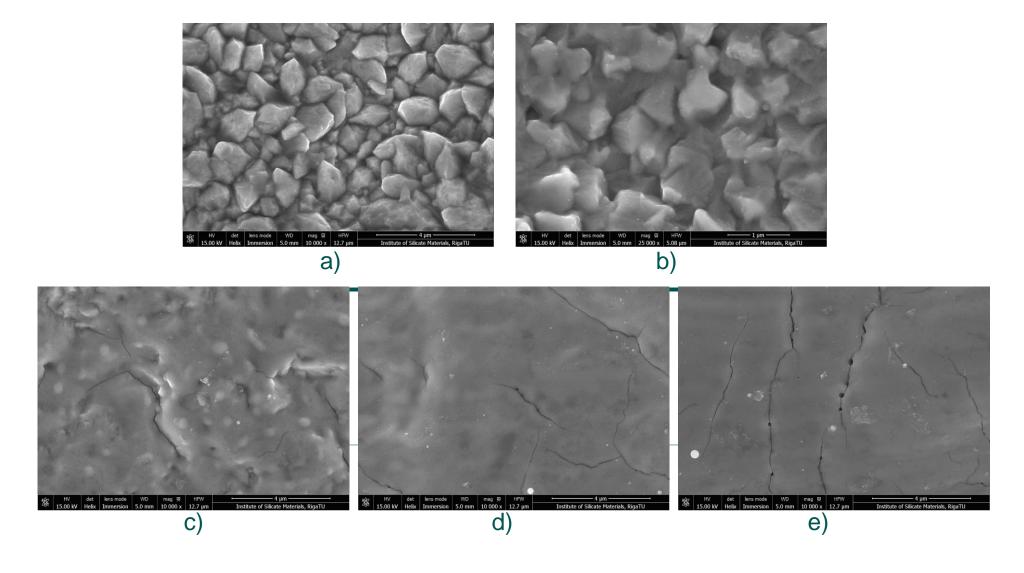


Fig.3. SEM images of Nb/Cu sample Nr.22/3/16 before irradiation (a) and after irradiation by Nd:YAG laser with Intensities:  $I_1$  = 140 MW/cm² (b);  $I_2$  = 170 MW/cm² (c);  $I_3$  = 253 MW/cm² (d);  $I_4$  = 320 MW/cm² (e).

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